Effect of Manganese Doping Percentage on Band Gap Energy of Cadmium Sulphide (CdS) Nanofilms Prepared by Electrodeposition Method

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Abstract: Cadmium sulphide (CdS) nanofilms with different Mn percentage doping were prepared by electrodeposition method at room temperature using aqueous solution of cadmium chloride, manganese chloride, sodium thiosulphate andtriethanolamine as the complexing agent,. The XRD studies showed that the Mn doped CdSnanofilms have cubic structure with crystallite sizes of range 0.288 to 2.739nm. The thickness of the films determined by optical method were ofrange 2.04nm to 20.82nm. The band gap energy of CdSnanofilms increased with the increasing of Mn percentage doping and their values of range 2.02eV to 2.35 eV were slightly lower than 2.42eV, the literature value for bulk CdS. The observed decrease in band gap energy values of CdSfilms with different Mn percentage doping may be due to sp–d exchange interaction between the band electrons and localized d- electrons of Mn ions substituting Cd⁺² ions. Such Mn doped CdS films could be suitable for applications in thin films solar cells fabrications, photo-thermal and optoelectronic devices.

Keywords: Effect of Manganese percentage doping, bandgap energy, Cadmium sulphidenanofilms, Electrodeposition

1. Introduction

Recently, there has been an increase in research and development of nanostructured II-VI semiconductor materials owing to their importance in basic scientific researches and potential technological applications [1]. Such nanostructured materials exhibit unusual physical and chemical properties in comparison with their bulk materials, such as size dependent variation of band gap energy and have many potential applications in photochemistry, catalysis and electronic/optical materials [2,3].

Cadmium sulphide (CdS) as an important II-VI semiconductor with direct band gap of 2.42eV at room temperature is a promising candidate for solar cells, green lasers, photoconductors, light emitting diode and thin film transistors, photochemical catalysis, gas sensors, detectors for laser and infrared, display screen,nonlinear optical materials, various luminescence devices, optoelectronic devices and so on [1,2, 4,5,6,7,8,9,11,12,13,14].Optical constant as an input data in design process of the thin film devices gives the designer an additional tool for optimization of the product design, thus an accurate knowledge of optical constant over wide range of wavelength is essentially important [7].

Transition metal doped semiconductors known as dilute magnetic semiconductors, have attracted wide spread scientific attention due to their prospective applications. The doping of transition metals (such as Mn, Fe, Co, Ni) into II – VI semiconductors has led to unique optical, electrical, chemical andmechanical properties which cannot be found in undoped materials (15). Dilute magnetic semiconductors (DMSs) offer great opportunity to integrate electrical, optical and magnetic properties into a single material which makes them ideal candidate materials for nonvolatile memory, magneto-optical, optoelectronics and

futurespintronic devices [1]. Group II – VI semiconducting chalcogenides, such as Cadmium sulphide, owing to its wide band gap energy, is found suitable for use as host material for variety of transition metal dopants [1].

2. Literature Review

The optoelectronic properties, particle sizes and morphologies of nanomaterials have close relation to preparation conditions [11]. Cadmium sulphide can exist in form of stable hexagonal phase or cubic phase or a mixed phase [5]. Cadmium sulphide with cubic structure had been reported by many authors [6,10,16]. The transmission of light through dopedCdS films decreases with increasing film thickness and dopant concentration [17, 18]. A shift for absorption edge towards the shorter wavelength with increase in doping concentration has been reported [17,18,19,20]. Decrease in band gap can be attributed to the influence of various factors such as grain size, structural parameters, carrier concentration, presence of impurities, deviation from stoichiometry of the film and decrease in the lattice strain [17].

Doping semiconductors with transition metal ions opens up possibilities of forming a new class of materials and new properties of the materials are expected. Transition metals are most interesting impurities as they introduce deep levels in the gap region, which can influence not only optical characteristics but also electrical and magnetic properties thereby influencing their practical applications, [20]. Dilute magnetic semiconductors provide the possibility of tuning parameters such as band gap and lattice constants by varying the composition of the material [19]. The variation in band gap can be due to the influence of the various factors such as grain size, structural parameters, carrier concentration, presence of impurities, deviation from stoichiometry of the film and decrease in the lattice strain [17]. The decrease in

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the band gap energy reported for transition metaldoped CdS material can be ascribed to sp-d exchange interaction between the band electrons and localized d- electrons of dopant ions substituting Cd⁺² ions [16].Controlling the size and dimensionality of DMS structures is an additional powerful way to tune their properties via quantum confinement effects [21].

Different deposition methods had been reported for cadmium sulphide (CdS) thin films, but solution growth techniques are probably the most explored approach.. In this work,electrodeposition method was adopted for the preparation of manganese doped cadmium sulphide (CdS:Mn) nanofilms.Electrodeposition method does not require high temperature and pressure selectivity [5]. Furthermore, this method is scalable with high degree of controllability and reproducibility, hence it is widely applied commercially[22]. The electrodeposition process involves multiple reactions which include reduction, formation and crystallization, (Sharma *et al.*, 2004).

The main purpose of this study is to investigate the effect of manganese percentage doping on the band gap energies of CdSnanofilms prepared byelectrodeposition method and to proffer the possible applications of such DMS nanofilms.

3. Materials and Method

All the chemical used for the cathodicelectrodeposition of manganese doped cadmium sulphide (CdS:Mn) nanofilms were of analytical grade and all solutions prepared in deionized water (Alpha-Q-millipore). The CdS:Mnnanofilms were prepared from acidic bath containing aqueous solutions of 10ml of 0.05M cadmium chloride (CdCl₂.2¹/₂H₂O) as Cd^{+/} ions precursor, 10ml of 0.05M manganese chloride (MnCl_2.4H_20) as Mn^{+2} ions precursor, 10ml of 0.05M sodium thiosulphate (NaS₂O₃.5H₂O) as S²⁻ ions precursor, 10ml of 0.05M tri-ethanolamine (TEA) as a complexing agent. Few drops of 1.0M hydrochloric acid (HCl) were used to control the PH of the electrolyte in the reaction bath. Prior to deposition, the ITO glass substrates were degreased with ethanol for 10 minutes; then ultrasonically cleaned with de-ionized water for another 10minutes and finally dried in a desicator. Thesurface of the platinum plate was thoroughly beakers polished andall glass / measuring cylindersthoroughly washed with de-ionized water.

The experiment was carried out using acidic bath of PH 3, at room temperature, optimum deposition time of 240 seconds and optimum deposition voltage of 4.0 Volts while manganese doping percentage in the reaction bath was varied from 3% to 23%. The reactions involve chelating of Cd^{2+} and Mn^{2+} ions with complexing agent, tri-ethanolamine to form a complex ions, CdMnTEA²⁺ which then react with the S²⁻ ions produced from sodium thiosulphate solution to form CdMnS compound at the cathode (ITO glass substrate). The deposited CdS: Mn films were rinsed with de-ionized water, dried, annealed at the temperature 250° .C and kept for analysis.

The structural analysis of Mn doped CdSnanofilms was studied by X-ray Mini Diffractometer, model MD 10.The optical studies of manganese doped cadmium sulphidenanofilms were carried out by JENWAY 6405 UV-Vis Spectrophotometer within the wavelength range of 280nm to 1100nm. The absorption coefficient α of the film samples is determined by the equation;

 $\alpha = A/\lambda \ \dots \ 1$

where A is the absorbance of the film and $\boldsymbol{\lambda}$ is wavelength of incident radiation.

Near the absorption edge the absorption coefficient is related to the band gap, Eg by the equation;

The band gap energy (Eg) of the films are respectively obtained from allowed transition by extrapolating the graph of α^2 versus (hu) to the point where α^2 is zero.

4. Results and Discussion

The XRD pattern of the CdS:Mn film (with 8% Mn) deposited on ITO glass substrate is shown in Fig. 1. The crystals of CdS:Mn film were of cubic structure with preferential growth along (400) direction and lattice constant of a = b = c = 10.176 Å. The crystallite size of the film sample calculated using Debye-Scherrer's formula ranged from 0.2878nm to 2.7386nm with mean crystallite size of 1.1394nm.



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The mean dislocation density value 6.2403 and microstrain of 0.739 may be attributed to interstitially substituted Mn .impurity atoms or due to adsorbed colloidal Cd in the film samples. Similar CdS cubic structure had been reported for CdS prepared using cadmium complex compounds and thioacetamide[10],CBD method at a temperature of 80°C [6].and co-precipitation method [16]

The thickness of theMn doped CdS films determined using optical method ranged from 2.04nm 20.82nm confirming the nanometer size of the film samples. The transmission spectra of Mn doped CdS:Mnnanofilms (with different Mn percentage doping) are shown in Fig.2



Figure 2: Transmittance spectra of ZnS:Mn films with different Mn doping%

All the films have high transmittance (>70%) beyond the absorption edge. At wavelength of 550nm in the visible region, the average transmittance of the CdS: Mn film samples increased from 0.87 to 0.88 as Mn doping % increased from 3% to 18% and then decreased to 0.80% as

Mn doping % increased to 23%. The high transmittance of the film samples may be ascribed to the thinness of the films. The optical absorption spectra of CdS:Mnfilms with different Mn percentage doping are shown in Fig. 3.



Figure 3: Absorption spectra of ZnS:Mn films with different Mn doping%

The absorption coefficient (α) of all the CdS:Mn films were relatively high in the wavelength range of 300 – 350nm and zeroed from the wavelength of 700nm.At wavelength of 550nm in the visible region, the average absorption coefficient of Mn dopedCdS films decreased from 0.25 x 10⁶ to 0.10 x 10⁶ as Mn doping % increased from 3% to 8% and then increased to 0. 25 x 10⁶ as Mn doping % increased to 23%. However, the film sample doped with 18% Mn (P₂C₄) exhibited low absorption coefficient of 0.10 x 10⁶. The obtained magnitude of absorption coefficient 10⁶ is within the range of 10⁶ to 10⁻⁷ required for the fabrication of semiconductor thin film solar cells [24]. The absorption edge of all theCdS:Mn films fall within the shorter wavelength range 300nm-320nm compared to 515nm reported for bulk cubic CdS, thus suggesting that they are blue shifted.[10].The blue shift in absorption edge may be attributed to quantum confinement of the excitons present in the film samples, resulting in a more discrete energy spectrum of the individual particles [2]. Similar results had been reported for Cu,Fe co-doped CdS [1], Mn,Ce co-doped CdS,[11],Mn - doped CdS [4]andCl - doped CdS films.[17]Such films with high absorption coefficient in the visible region could be employed as widow materials in variousphoto-thermal and optoelectronic devices [1,25].

The optical band gap values of CdS:Mnnanofilms were obtained by extrapolating the linear part of the curves of α^2 versus hu to huaxis where $\alpha = 0$ as shown in Fig. 4.

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Figure 4: Plot of α^2 versus hu for ZnS:Mn films with different Mn doping%

The band gap energy of CdSnanofilms increased from 2.02eV to 2.35eV as Mn doping % increased from 3% to 18% and then decreased to 2.12eV as Mn doping % increased to 23%. The highest optical band gap value (2.35eV) was obtained from the film sample (P_2C_4) doped with 18% Mn.The results revealed that the band gap energy values of the CdS: Mnnanofilms of range 2.02eV to 2.35 eVwerelower than 2.42eV reported for forundopedCdS[5] but compare favorably with the band gap energy range 2.30eV to 2.38eVreported for Mn doped CdS films prepared by chemical bath deposition method [4],2.36eV for mercury doped CdS films[25],2-35eV for Cu doped CdS [16], 2.20eV for Cu,Fe co-doped CdS [1] and 2-35eV for undoped,CdS [7]. Although the obtained band gap values are lower than the CdS, bulk value, their value increase with the increasing of percentage doping, The decrease in the band gap energy observed in the doped CdSnanofilms may be due to sp-d exchange interaction between the band electrons and localized d- electrons of Mn ions substituting Cd⁺² ions [16]. The difference in the band gap energy values of CdS with different Mn content confirmed that Mn doping % strongly influenced the band gap energy of the film samples Such directband gap Mn doped CdSnanofilms with a wide range of band gap energy values could be employed for the thin films solar cells fabrications and various optoelectronic devices applications [1,2,4,5,7].

5. Conclusion

Manganese doped cadmium sulphide (CdS:Mn) nanofilms were successfully prepared by electrodeposition method using acidic bath containing aqueous solution of cadmium chloride, manganese chloride, sodium thiosulphate and a complexing agent, triethanolamine. The XRD pattern of CdS:Mnnanofilms revealed that the crystals of the film have cubic structure. The thickness of the films were found to be in nanometer sized range. We investigated the effect of manganese percentage doping on band gap energy of CdSnanofilms. The results showed that the obtained band gap energy values were lower than 2.42eV reported for the undoped bulkCdS but increase with the increasing ofMn percentage doping. Such CdS:Mnnanofilms with wide range of direct band gap energy values could be employed for thin films solar cells fabrications and various optoelectronic devices applications.

We recommend that more research work be carried out on Mn doped CdSnanofilms using other methods of deposition.

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References

- Hasanzadeh J.;Shayesteh F.S; and Ziabari A.A. (2014). "Effect of PH on the Optical properties of doped CdS(Cu,Fe) nanoparticles incorporated in TG as a capping agent", ACTA PhysicaPolonica A, 120, 713-716
- [2] Khalid T. A-R; Nada K.A; Zainb J.S. (2013);
 "Structural and Optical Characterization of Cu and Nidoped CdS nanoparticles", Int. J. Electrochem. Sci. 8(2013), 5594-5604
- [3] Dang Q; Genwang.W; Christophers M.S and Kenneth J.K; (2009); "Cadmium (Zinc) manganese sulphidenanocrystalline (Cd_{1-x}Mn_xS and Zn_{1-x}Mn_xS) dilute magnetic semiconductors: synthesis, annealing and effects of surface oxidation on magnetic properties", Arabian Journal of Chemistry, 41, 63-68.
- [4] Alvan, S.H; Abdulhadi K.T; Attalia B.H; (2010);
 "Optical, electrical and structural properties of Mn doped CdS prepared by CBD"; Journal of College of Education, 1(1), 76-90
- [5] Anuar K.I; Zainal Z.I; Nagalmgam S; Muhammed N, Razak S. (2005); "Effects of deposition periods and solution temperatures towards the properties of CdS thin films prepared in the presence of sodium tartrate"; Materials Science, 11 (2), 10-15.
- [6] Choi J.Y; Kim K.Y, Yoo J.B. and Kim D. (1998); "Properties of CdS thin films deposited by ultrasonication"; Sol. Energy 64(1-3), 41 -47
- [7] Ziaul, R.K; Zulfequar, M; Shahid K.M; (2010); "Effect of thickness on structural and optical properties of thermally evaporated cadmium sulphide polycrystalline thin films"; Chalcogenide Letters 7(6), 431-438

- [8] Murugadoss C. (2012); "Synthesis of high quality and monodisperse CdS:Mn²⁺/ZnS and CdS:Mn²⁺/CdS core shell nanoparticles superlattices and microstructures"; 52 (2012), 1026-1042
- [9] Srinivasa, R; Bajesh Kumar B; Venkata C.G; Rajagopel R.V; Subba R.T; (2011); "Structural properties of Ni doped CdS". J. Nano. Electron. Phys. 3(1), 620-625.
- [10] Dumbrava A; Badea C; Prodan G. Ciupina V; (2010);
 "Synthesis and Characterization of Cadmium sulphide obtained at room temperature; Chalcogenide Letters, 7(2), 111-118
- [11] Sreenivas, M; Harish G.S and Reddy P.S. (2014), "Synthesis and Characterization of Mn, Ce co-doped CdS nanoparticles synthesized via co-precipitation method"; International Journal of Modern Engineering Research. (IJMER),4(9), 10-16
- [12] Verma, P; Manoj, G.S; Pande, A.C. (2010); "Organic capping effect and mechanism in Mn-doped CdSnano composites"; Physics B: Condensed Matters, 405 (5), 1253-1257.
- [13] Liu, S; Liu, F; Guo, H; Zhang, Z; Wang, Z; (2000);
 "Surface states induced photoluminescence from Mn²⁺ doped CdS nanoparticles"; Solid State Communications 115 (2000), 615-618
- [14] Cui, H.N; Teixero, V; Meng L.J; Zhang H.J. (2004);
 "Studies on microstructure bi-layer film of ultrasonic dipped CdS and DC sputtered indium tin oxide (ITO)!; Thin solid films, 444-448, 663-668
- [15] Thi, T.M; Tinah I.V; Van, B.H; Ben P.V. and Trung V.Q; (2012); "The effect of polyvinylpymolidone on the optical properties of the Ni-doped ZnSnanocrystalline thin films synthesized by chemical method"; Journal of Nanomaterials, 2012, Article ID 528047
- [16] Sreelekha, N; Subramaniam, K; Murali G; Giribabu,
 G; Vijayalakhimi, R.P. Madhusudhana R. (2014);
 "Effect of Cu doping on structural and optical properties of CdS nanoparticles"; International Journal of Chem. Tech Research, CODEN USA, 6(3), 2113-2116
- [17] Al-Shammari, A.;,Mulla A.F and Al-Dhafiri, A.M; (2005); "Preparation and characterization of chlorine doped Cadmium sulphide (CdS:Cl) thin films and their applications."; M.Sc Thesis, King Saud University, College of Science, Department of Physics, Riyadh. Saudi Arabia.
- [18] GodeF.andGumus, C; (2009); "Influences of copper and manganese concentrations on the properties of polycrystalline ZnS:Cu and ZnS:Mn thin films", Journal of Optoelectronics and Advanced materials, 11(4), 429-436
- [19] Rojas-Hernadez, A.G; Mendivil-Reynoso, T; Acosta-Enriquez, M.C; (2012); "Comparison of properties of cadmium, copper and lead sulphides thin films grown by CBD"; Chalcogenide Letters, 9 (3), 121-126.
- [20] Pathak, C.S; Pathak, P.K; Kumar, P; Mandal, M.K; (2012); "Characterization and Optical properties of Ni²⁺ doped ZnS nanoparticles"; Journal of Ovonic Research 8(1), 15-20
- [21] Kadiran, F; Mao D, Song Wal;Ohno, T; McCandlessB; (2000); "Properties of electrodeposited CdS for

photovoltaic device with comparison to CdS prepared by other methods"; Turk. J. Chem. 24, 21-33

- [22] Sharma, R.K, Rostigi, A.C; Singh, G; (2004); "Electrochemical growth and characterization of manganese telluride thin films" Materials Chemistry and Physics, 84 (2004), 46-51
- [23] Ilenikhena, P.A. (2008); "Comparative studies of improved copper sulphide (CuS) and Zinc sulphide (ZnS) thin films at 320K and possible applications"; African Physical Review, 2(7), 59-67
- [24] Eleruja, M.A; Adedeji, A.V; Olofinjana, B; Akinwunmi, O.O; Ojo, I.A; Egharaba, G.O; Osasona O. and Ajayi, E.O.B; (2010); "Preparation and characterization of mercury cadmium sulphide thin films"; Journal of Non-Oxide Glasses, 2(4), 175-185.